

A METHOD FOR MAKING PHOTSENSITIVE FIBER SUITABLE FOR WAVELENGTH STABILIZATION GRATINGS

BACKGROUND OF THE INVENTION

Field of Invention

5 The present invention is generally directed to devices for optical communications, and more particularly to a method for making photosensitive fiber suitable for wavelength stabilization gratings.

Description of the Related Art

10 Wavelength stabilization gratings (also referred to as laser stabilization gratings) are weak fiber Bragg gratings used to lock a semiconductor laser to a particular emission wavelength. They are typically a few tenths of a nanometer wide and reflect a small percentage of the incident light, e.g. 1 to 10% of the guided power in the fiber.

15 Generally, wavelength stabilization gratings are fabricated using UV-induced index changes in a host fiber, such as a standard telecommunications type fiber. For 980-nm pump laser applications, these gratings are typically written in a 980-type fiber, such as Corning® CS-980™ fiber or Corning® Flexcor™ 1060 fiber. For 1480-nm pump laser applications, Raman amplifier pump applications, or signal laser applications, they may be fabricated in a fiber such as Corning® SMF-28™ fiber.

20 Additionally, gratings may be written in a polarization-maintaining (PM) fiber such as Corning® PureMode™ PM Engineered fiber, PM 980 or PM 1550.

 Hydrogen loading must be used with in standard telecommunications type fibers

to get the change in index required to make wavelength stabilization gratings. Hydrogen loading involves placing fibers in a chamber pressurized with hydrogen for extended periods of time at very high pressures, e.g., up to 12 days at 20-750 atm pressure. The loaded fibers are then stored at very cold (e.g. -80°C) temperatures to prevent outdiffusion of H₂. After grating formation, the gratings are thermally annealed to stabilize the index change, typically with a 24 hour anneal cycle at 140°C.

It would be preferable to remove the need for hydrogen loading. Hydrogen loading introduces several processing steps which may be preferable to avoid in manufacturing situations. This leads to increased manufacturing costs due to: increased processing steps, pressure chamber safety concerns, processing variability due to hydrogen out-diffusion, low temperature storage cost, and annealing requirements, among others. In addition, hydrogen loading is a long and expensive process. Therefore, it would be desirable to have a method of fabricating wavelength stabilization gratings which does not require hydrogen loading.

SUMMARY OF THE INVENTION

The present invention includes a method of making a preform for an enhanced photosensitive fiber comprising the steps of depositing successive layers of optical material inside a tube using modified chemical vapor deposition, and collapsing the successive layers of optical material in a reducing atmosphere with a positive pressure. Preferably, the positive pressure is between 0 and 1.0 torr. Additionally, the reducing atmosphere preferably comprises He.

The present invention also includes a method of making an enhanced photosensitive fiber comprising the steps of making a preform using modified chemical vapor deposition wherein the preform is collapsed in a reducing atmosphere with a positive pressure and drawing the preform into a fiber. Preferably, the positive pressure is between 0 torr and 1.0 torr. Additionally, the draw tension is preferably between 100 g and 250 g and the draw temperature is preferably between 1950°C and 2100°C.

BRIEF DESCRIPTION OF THE DRAWINGS

The foregoing and other features, aspects and advantages of the present invention will become apparent from the following description, appended claims and the exemplary embodiments shown in the drawings, which are briefly described below.

Figure 1 is a plot illustrating the effect of an oxygen deficient collapse on the index.

Figure 2 is a plot illustrating the effect of draw tension on the index.

Figure 3 is a plot illustrating the index as a function of exposure time.

Figure 4 is a plot illustrating the index as a function of exposure time.

Figure 5 is a cross section of a fiber Bragg grating according to a first embodiment of the invention.

Figure 6 is a cross section of a first embodiment of the invention illustrating the definition of the grating period Λ .

Figure 7 is a table summarizing the effect of various manufacturing parameters for GeO_2 doped MCVD fibers.

Figure 8 is a table summarizing the effect of various manufacturing parameters for $\text{GeO}_2\text{-B}_2\text{O}_3$ -doped MCVD fibers.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

The present inventors have determined that optical fibers with enhanced photosensitivity can be manufactured by the modified chemical vapor deposition (MCVD) process, also known as the inside vapor (IV) deposition process, with careful control of various process parameters. These process parameters include the collapse condition and draw conditions, including draw temperature and tension. For example, optical fibers can be fabricated without hydrogen loading that exhibit changes in index up to approximately 1×10^{-3} when exposed to UV light. Thus, wavelength stabilization

gratings can be fabricated in these fibers more quickly and at a significantly lower cost than using prior art procedures.

The degree of photosensitivity of an optical fiber manufactured by the MCVD process is a function of the collapse conditions and the draw conditions. Figures 7 and 8 summarize the effects of various collapse conditions on GeO_2 doped MCVD fibers and $\text{GeO}_2\text{-B}_2\text{O}_3$ doped fibers, respectively. Each preform was collapsed in three successive stages. In most cases, the three collapse conditions were identical, e.g., the gas flow composition was held constant. In some cases, however, gas composition was changed after the first collapse, but held constant during the second and third collapse. Gases used include O_2 , Cl_2 , GeCl_4 , He, and 2-propanol. The helium is used to produce an oxygen deficient collapse. Solid bullets indicate a gas was present during all three collapse stages, while numbers in parentheses indicate a gas was used only during that particular collapse stage. Where exact GeCl_4 flow rate is known, it is specified. Bullets indicate an unknown flow rate between 50-280 sccm GeCl_4 . The temperature of the 2-propanol vessel was varied from room temperature up to 75°C , as indicated. The 2-propanol was used so that (1) hydrogen from 2-propanol might create the same effect as H_2 treatment and (2) carbon might create a reduced environment so that more oxygen deficient centers are created.

Figure 1 illustrates the effect of an oxygen deficient collapse on the index. The change in index was induced by exposing the fiber to a 240 nm UV laser operating at 10 Hz and a fluence of approximately 280 mJ/cm^2 for about 15 minutes. As can be seen in the figure, collapsing under oxygen deficient conditions results in significantly higher photosensitivity. The highest changes in index are produced when all three collapse stages are oxygen deficient (solid oval). However, having at least one oxygen deficient collapse stage also results in improved photosensitivity (dotted oval). The fibers with the lowest photosensitivity were fabricated by the outside vapor (OV) process. In the preferred embodiment of the invention, oxygen deficiency is achieved by using helium as the primary gas. However, other inert gases, such as argon and nitrogen may also be used.

In addition to collapsing with an oxygen deficiency, the inventors have determined that it is desirable to collapse under positive pressure. Preferably, the

collapse pressure should be between 0 and 1 torr. More preferably, the collapse pressure should be between 0 and 0.5 torr. Most preferably, the collapse pressure should be between 0.2 and 0.4 torr.

In the preferred embodiment of the invention, the preform is doped with Ge. However, the preform may also be co-doped with B_2O_3 . This is especially advantageous for the fabrication of cladding mode suppression (CMS) fibers. CMS fibers are designed to have both a photosensitive core and a photosensitive cladding layer.

The effect of draw conditions on the photosensitivity is illustrated in Figure 2. An increase in draw tension increases the photosensitivity of the fiber. Further, a decrease in draw temperature increases the photosensitivity. This increase in photosensitivity was produced in both Ge-doped fibers and B-Ge-doped fibers. In the preferred embodiment of the invention, the preform is drawn with both a high tension and under low temperature. Preferably, the draw tension is between 100g and 250g. More preferably, the draw tension is between 150g and 200. The draw temperature is preferably between 1950°C and 2100°C . More preferably the draw temperature is between 1980°C and 2050°C . Most preferably, the draw temperature is between 1980°C and 1990°C .

Figures 3 and 4 are plots of the normalized modulated index of a assortment of GeO_2 doped fibers as a function of exposure time. The figures illustrate that both the degree of photosensitivity, as measured by the magnitude of the change in index, and the rate of change of the index is a function of the various process parameters. A combination of a preform collapsed with three oxygen deficient stages, high draw tension and low draw temperature produces the largest change in index and the fastest change in index. Collapse with oxygen, a low draw tension and a high draw temperature yields the smallest index and the slowest rate of change. By varying one or more of the parameters, intermediate degrees of photosensitivity and intermediate rates of change can be achieved.

Because the process parameters may be varied singly or in combination, it is possible to tailor and optimize the fiber response based on the desired end product. For example, it is possible to design a fiber which achieves an index suitable for laser

stabilization gratings with an exposure of less than 15 minutes. Further, a fiber may be fabricated which achieves an index suitable for laser stabilization gratings with an exposure of less than 5 minutes. It is also possible to achieve a suitable index in less than 1 minute or even within 30 seconds.

Figure 5 presents a cross section of a grating 1 in a fiber according to a first embodiment of the invention. The grating may be a fiber Bragg grating, a long period fiber grating, a laser stabilization grating or any other type of grating. The grating 1 has a core 3 comprising a material with enhanced photosensitivity. Example materials include, but are not limited to germanium doped silica and germanium and boron co-doped silica prepared from a preform collapsed in a reducing atmosphere with a positive pressure. Preferably, the core 3 is surrounded by a cladding layer 5 which has an index of refraction lower than the index of refraction of the core.

Within the core 3, is a region 7 which contains a regular array of periodic, permanent perturbations 13 of the index of refraction. The array of perturbations 13 form an optical grating having a grating period Λ . Figure 6 illustrates the grating period Λ . The array of perturbations 13 are formed by exposing the fiber to UV light pulses through a mask. Preferably, the light is supplied from a 240 nm frequency doubled 480 nm dye laser pumped by a 351 nm excimer laser, however other lasers may be used. For example, the following lasers may also be used: 248 nm KrF excimer, 193 nm ArF excimer, 244 nm continuous wavelength frequency doubled Ar and other UV lasers with wavelengths in the range of 190 nm to 350 nm.

Preferably, the laser stabilization gratings are made from fibers drawn with a large tension and at a low draw temperature. However, it is not necessary that the tension be large and the draw temperature be low. It is sufficient that the combination of processing parameters produce a fiber with a high enough photosensitivity such that exposure to UV radiation increases the index enough to form laser stabilization gratings without hydrogen loading the fiber.

The foregoing description of the invention has been presented for purposes of illustration and description. It is not intended to be exhaustive or to limit the invention to the precise form disclosed, and modifications and variations are possible in light of the above teachings or may be acquired from practice of the invention. The drawings

Unit	Year	Value	Unit	Year	Value
1	1980	100	1	1980	100
2	1981	105	2	1981	105
3	1982	110	3	1982	110
4	1983	115	4	1983	115
5	1984	120	5	1984	120
6	1985	125	6	1985	125
7	1986	130	7	1986	130
8	1987	135	8	1987	135
9	1988	140	9	1988	140
10	1989	145	10	1989	145
11	1990	150	11	1990	150
12	1991	155	12	1991	155
13	1992	160	13	1992	160
14	1993	165	14	1993	165
15	1994	170	15	1994	170
16	1995	175	16	1995	175
17	1996	180	17	1996	180
18	1997	185	18	1997	185
19	1998	190	19	1998	190
20	1999	195	20	1999	195
21	2000	200	21	2000	200
22	2001	205	22	2001	205
23	2002	210	23	2002	210
24	2003	215	24	2003	215
25	2004	220	25	2004	220
26	2005	225	26	2005	225
27	2006	230	27	2006	230
28	2007	235	28	2007	235
29	2008	240	29	2008	240
30	2009	245	30	2009	245
31	2010	250	31	2010	250
32	2011	255	32	2011	255
33	2012	260	33	2012	260
34	2013	265	34	2013	265
35	2014	270	35	2014	270
36	2015	275	36	2015	275
37	2016	280	37	2016	280
38	2017	285	38	2017	285
39	2018	290	39	2018	290
40	2019	295	40	2019	295
41	2020	300	41	2020	300
42	2021	305	42	2021	305
43	2022	310	43	2022	310
44	2023	315	44	2023	315
45	2024	320	45	2024	320
46	2025	325	46	2025	325
47	2026	330	47	2026	330
48	2027	335	48	2027	335
49	2028	340	49	2028	340
50	2029	345	50	2029	345
51	2030	350	51	2030	350
52	2031	355	52	2031	355
53	2032	360	53	2032	360
54	2033	365	54	2033	365
55	2034	370	55	2034	370
56	2035	375	56	2035	375
57	2036	380	57	2036	380
58	2037	385	58	2037	385
59	2038	390	59	2038	390
60	2039	395	60	2039	395
61	2040	400	61	2040	400
62	2041	405	62	2041	405
63	2042	410	63	2042	410
64	2043	415	64	2043	415
65	2044	420	65	2044	420
66	2045	425	66	2045	425
67	2046				